

Oral Session (Material) | Material

📅 Thu. Sep 24, 2026 4:15 PM - 5:25 PM JST | Thu. Sep 24, 2026 7:15 AM - 8:25 AM UTC | 🏛️ Oral Session
Room 2 (Conference Room 501)

[Session 5] Thin film 1

💎 Invited Talk

4:15 PM - 4:35 PM JST | 7:15 AM - 7:35 AM UTC

[2R218] Top electrode Electronegativity Induced Coercive Field Asymmetry and Fatigue in PZT Thin Film

Yue Liu¹ (1. Shanghai Jiao Tong University)

💎 Invited Talk

4:35 PM - 4:55 PM JST | 7:35 AM - 7:55 AM UTC

[2R219] Understanding Structure-Property Relationships in Sc-Based Nitrides Contributing to High-Performance Devices

Masato Uehara¹ (1. National Institute of Advanced Industrial Science and Technology (AIST))

4:55 PM - 5:10 PM JST | 7:55 AM - 8:10 AM UTC

[2R220] An In-plane Polarization-inverted KNN Epitaxial Films for Planar Fresnel Lens and Ultrasonic Microscopy

Wataru Oda^{1,2}, Takahiko Yanagitani^{1,2} (1. Waseda University, 2. ZAIKEN)

5:10 PM - 5:25 PM JST | 8:10 AM - 8:25 AM UTC

[2R221] Analysis of piezoelectric response in BiFeO₃ epitaxial thin films grown on Si

Kira Fujihara¹, Takeshi Yoshimura^{1,2} (1. Osaka Metro. Univ., 2. Toyohashi Univ. Tech.)